

Physics of Low Temperature/Non-Equilibrium Plasmas

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June 22nd 2022, SULI Introduction to Fusion Energy and Plasma Physics Course



UNIVERSITY OF MINNESOTA

Driven to Discover[®]

About me

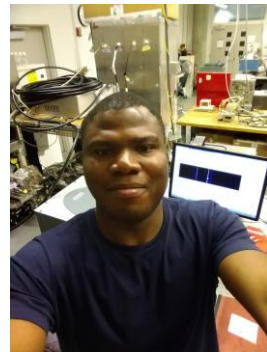
Yaoundé, Cameroon: Up to end of high school France (Troyes and Paris): Undergrad and Grad Studies



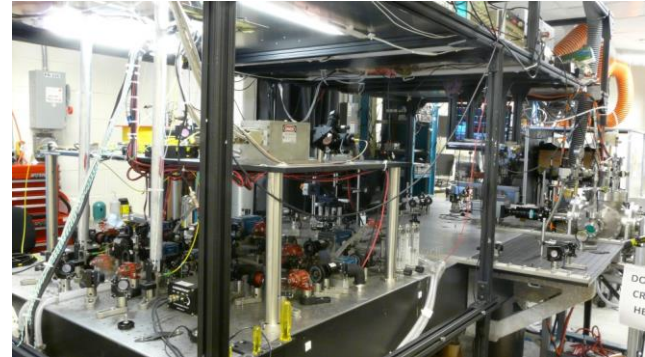
**THE Ohio State
University: Postdoc**



**University of Minnesota:
Research Associate**



**PPPL: Associate Research
Physicist**



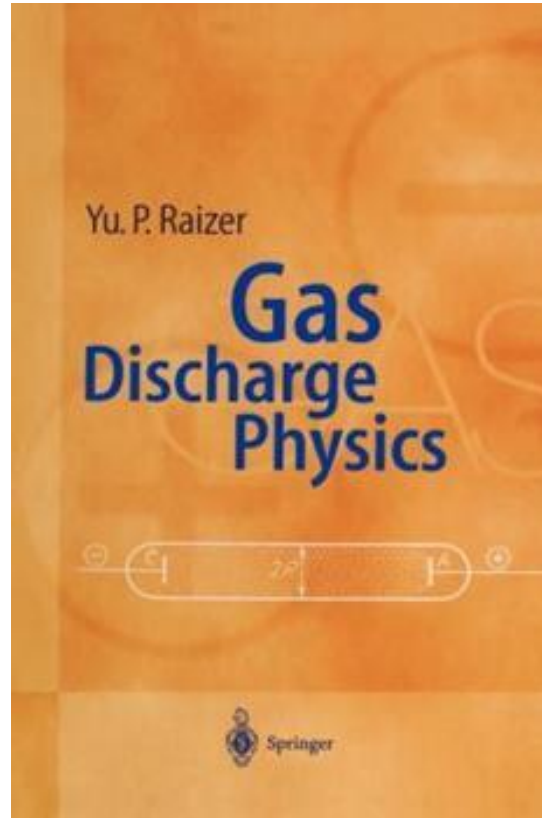
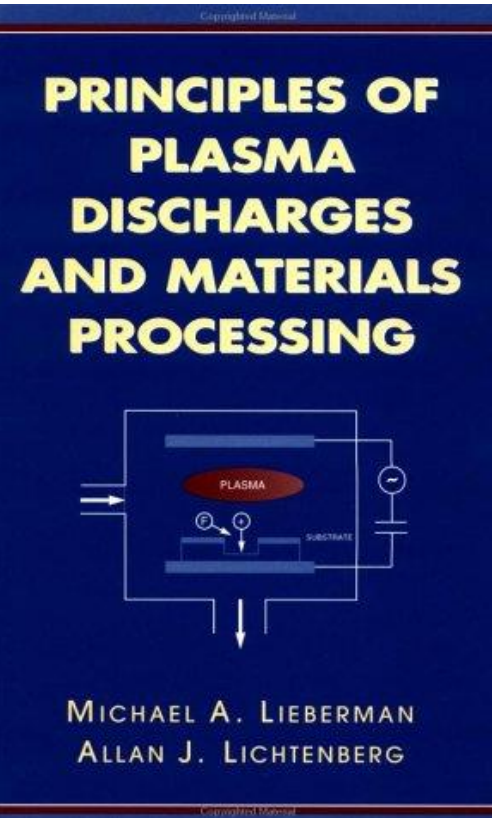
What time is it? *Game time!!*



- I am a huge fan of team sports, especially basketball and football (soccer in the US)
- I believe there are many similarities between how scientists and athletes prepare/operate
- Living on 3 continents, I have a strong interest in history of civilizations and cultures, as well as history of science



Some Good References



OPEN ACCESS
IOP Publishing

J. Phys. D: Appl. Phys. 50 (2017) 323001 (46pp)

Journal of Physics D: Applied Physics

<https://doi.org/10.1088/1361-6463/aa7615>

Topical Review

The 2017 Plasma Roadmap: Low temperature plasma science and technology

I Adamovich¹, S D Baalrud², A Bogaerts³, P J Bruggeman⁴, M Cappelli⁵, V Colombo⁶, U Czarnetzki⁷, U Ebert^{8,9}, J G Eden¹⁰, P Favia¹¹, D B Graves¹², S Hamaguchi¹³, G Hieftje¹⁴, M Hori¹⁵, I D Kaganovich¹⁶, U Kortshagen⁴, M J Kushner¹⁷, N J Mason¹⁸, S Mazouffre¹⁹, S Mededovic Thagard²⁰, H-R Metelmann²¹, A Mizuno²², E Moreau²³, A B Murphy²⁴, B A Niemira²⁵, G S Oehrlein²⁶, Z Lj Petrovic²⁷, L C Pitchford²⁸, Y-K Pu²⁹, S Rauf³⁰, O Sakai³¹, S Samukawa³², S Starikovskaia³³, J Tennyson³⁴, K Terashima³⁵, M M Turner³⁶, M C M van de Sanden^{9,37} and A Vardelle³⁸

IOP Publishing

Plasma Sources Sci. Technol. 26 (2017) 123002 (17pp)

Plasma Sources Science and Technology

<https://doi.org/10.1088/1361-6595/aa97af>

Topical Review

Foundations of atmospheric pressure non-equilibrium plasmas

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² Wolfson School of Mechanical, Electrical and Manufacturing Engineering, Loughborough University, Loughborough LE11 3TU, United Kingdom

³ Leibniz Institute for Plasma Science and Technology (INP Greifswald), Felix-Hausdorff-Strasse 2, D-17489 Greifswald, Germany



Outline

- ✓ **Low Temperature Plasmas and Applications**
- ✓ **Generation of Low Temperature Plasmas and Basic Properties**
- ✓ **Energy Partition and Transfer in Low Temperature Plasmas**
- ✓ **Case Study #1: Plasma-Assisted Ignition**
- ✓ **Case Study #2: Inactivation of Viruses and Bacteria**
- ✓ **Case Study #3: Polymer Etching**
- ✓ **Extra: Atmospheric Reentry**
- ✓ **Conclusion**



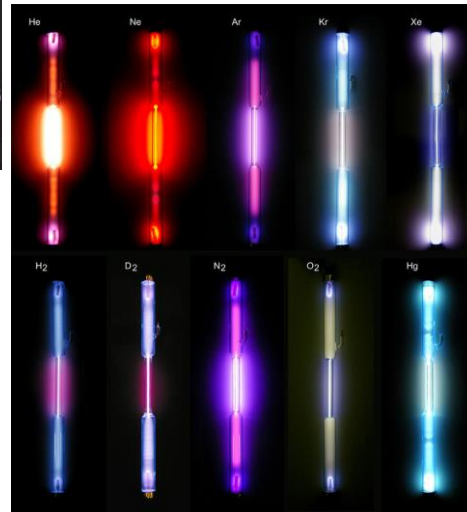
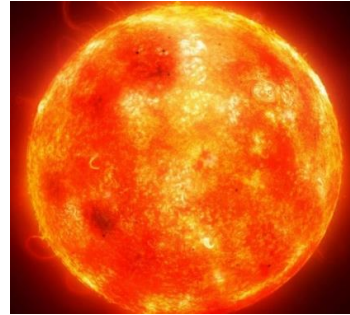
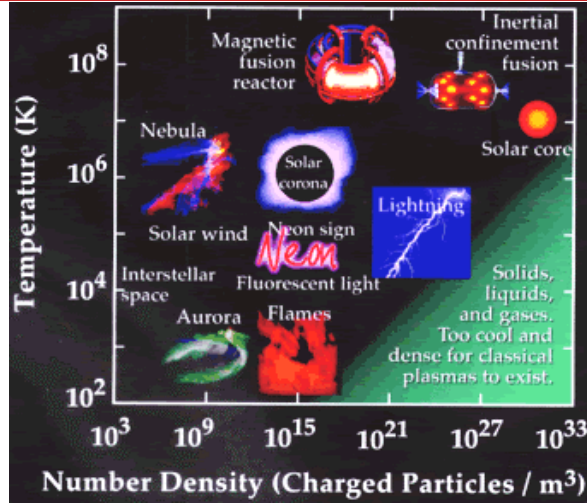
Low Temperature Plasmas and Applications





Plasmas?

- Ionized gases
- 4th state of matter
- 99.9% of the visible universe
- Made of neutral particles, free electrons, ions, electric fields, photons
- Span over several orders of magnitude of densities and temperatures

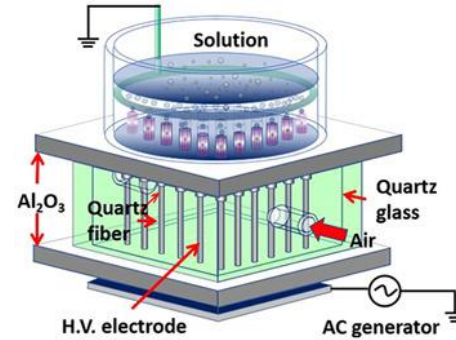
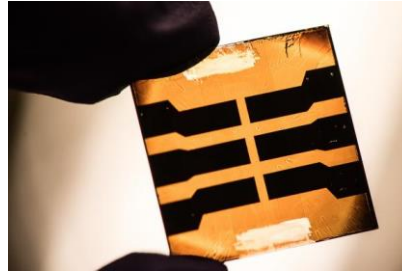


Current Grand Challenges of Engineering

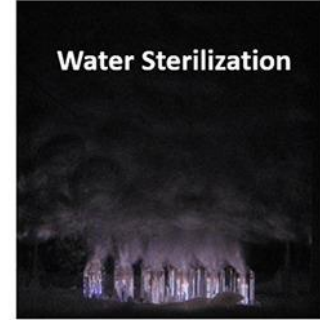
US Academy of Engineering

- Make solar energy economical
- Provide access to clean water
- Provide energy from fusion
- Manage the nitrogen cycle
- Engineer the tools for scientific discovery
- Improve CO₂ sequestration

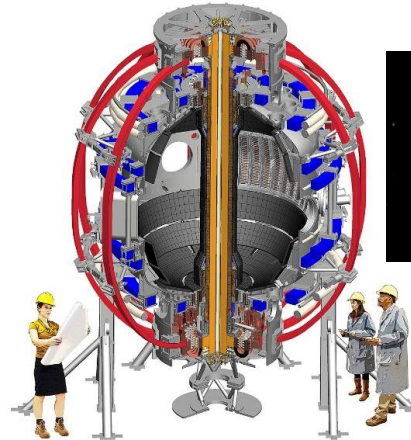
Perovskite solar cell



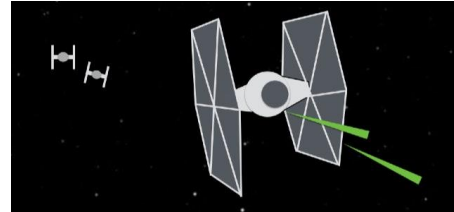
Water Sterilization



Spherical Tokamak at PPPL



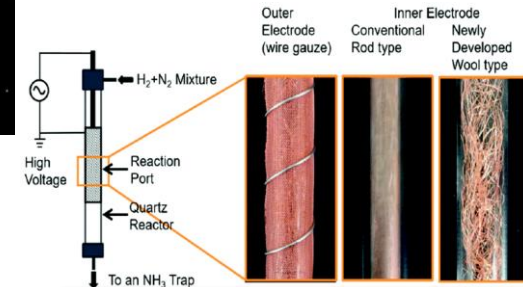
Electric propulsion for spacecraft



Star Wars twin ion engine fighters

Aihara *et al.* ChemComm(2016)

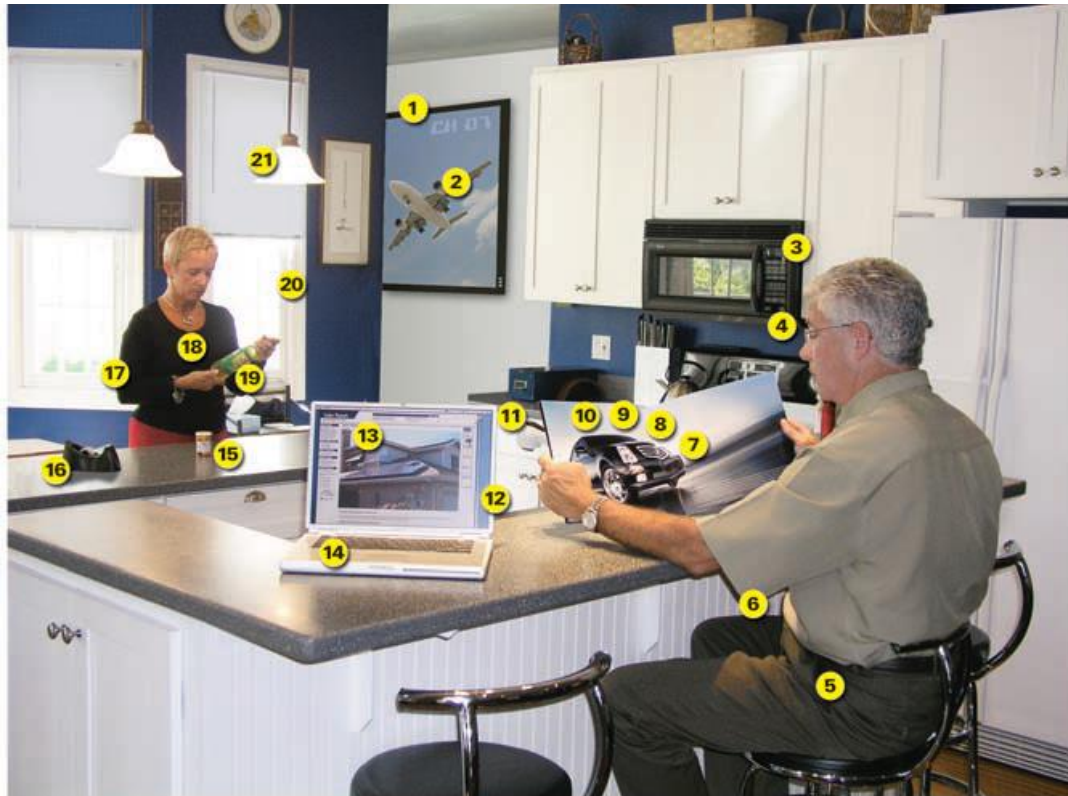
Plasma-assisted ammonia synthesis



Zhang *et al.* ACS Plasma Proc Polym (2018)



LT Plasmas Impact our Every-day Life

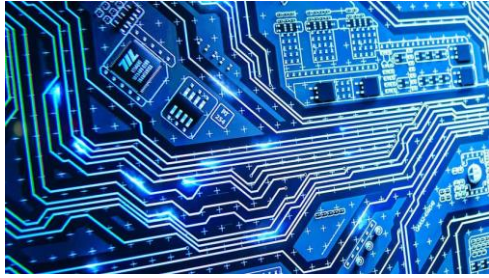


- 01 — Plasma TV
- 02 — Plasma-coated jet turbine blades
- 03 — Plasma-manufactured LEDs in panel
- 04 — Diamond-like plasma CVD eyeglass coating
- 05 — Plasma ion-implanted artificial hip
- 06 — Plasma laser-cut cloth
- 07 — Plasma HID headlamps
- 08 — Plasma-produced H₂ in fuel cell
- 09 — Plasma-aided combustion
- 10 — Plasma muffler
- 11 — Plasma ozone water purification
- 12 — Plasma-deposited LCD screen
- 13 — Plasma-deposited silicon for solar cells
- 14 — Plasma-processed microelectronic
- 15 — Plasma-sterilization in pharmaceutical production
- 16 — Plasma-treated polymers
- 17 — Plasma-treated textiles
- 18 — Plasma-treated heart stent
- 19 — Plasma-deposited diffusion barriers for containers
- 20 — Plasma-sputtered window glazing
- 21 — Compact fluorescent plasma lamp

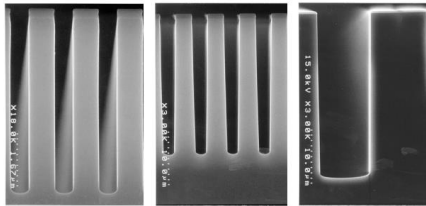
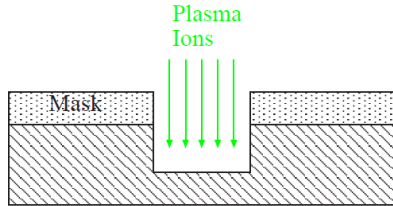
Plasma Science: Advancing Knowledge in the National Interest, National Research Council (US, 2007)



The Semiconductor Success Story



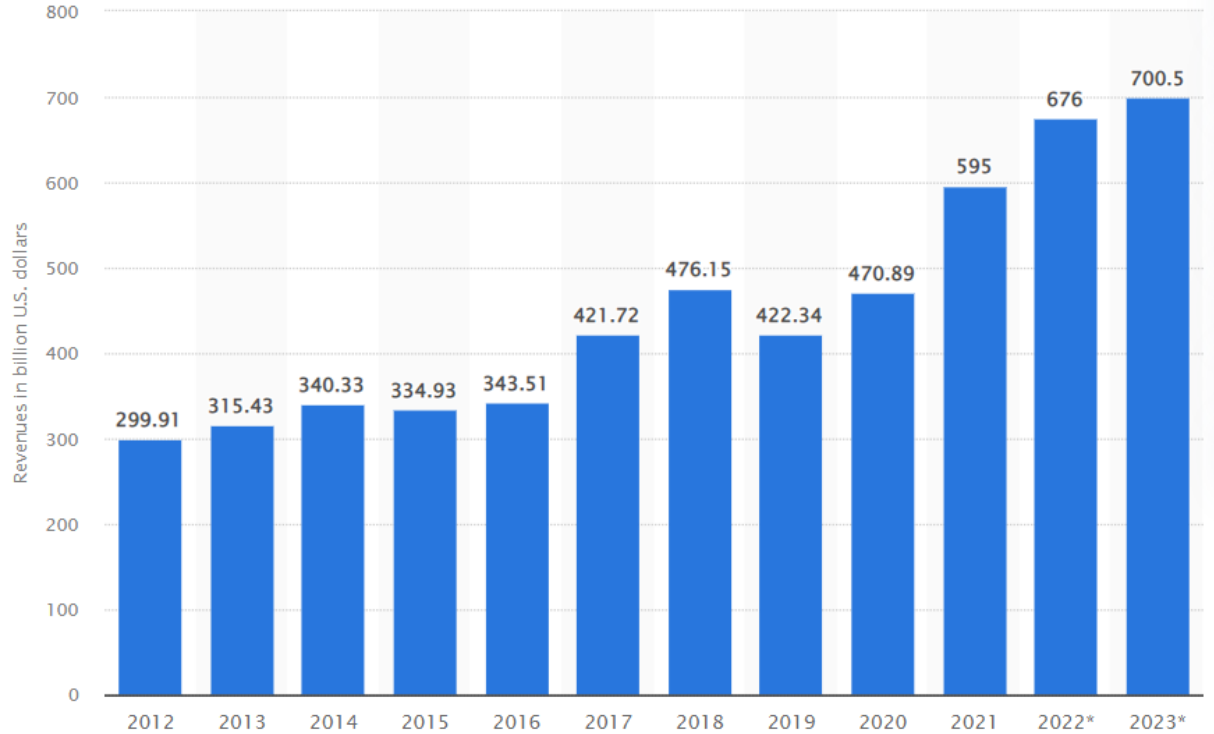
Anisotropic Plasma Etching



CD = 0.6 μ m
Trench Depth = 5.6 μ m
E/R = 1.9 μ m/min.

CD = 3 μ m
Trench Depth = 26 μ m
E/R = 3.2 μ m/min.

CD = 10 μ m
Trench Depth = 31 μ m
E/R = 3.9 μ m/min.



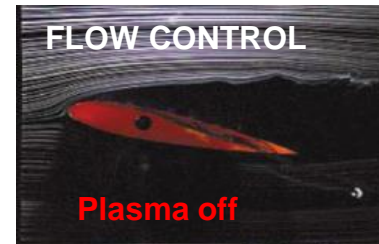
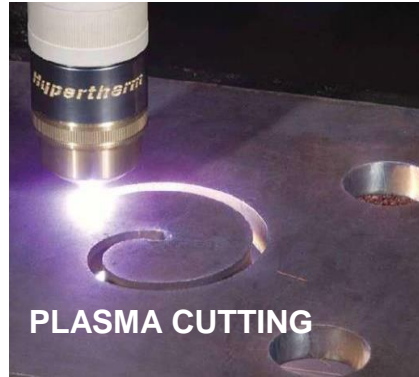
Wu et al, J. Appl. Phys. 108, 051101 (2010)



Plasmas and Applications: Thermal VS Non-Thermal

Thermal plasmas:

$$T_g \sim T_e (2,000 - 10,000 \text{ K})$$



Non-thermal plasmas:
 $T_g \ll T_e (10,000 \text{ K})$



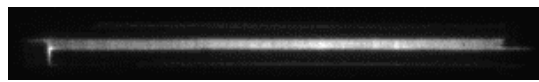
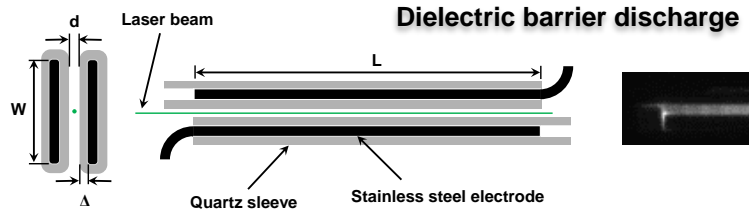
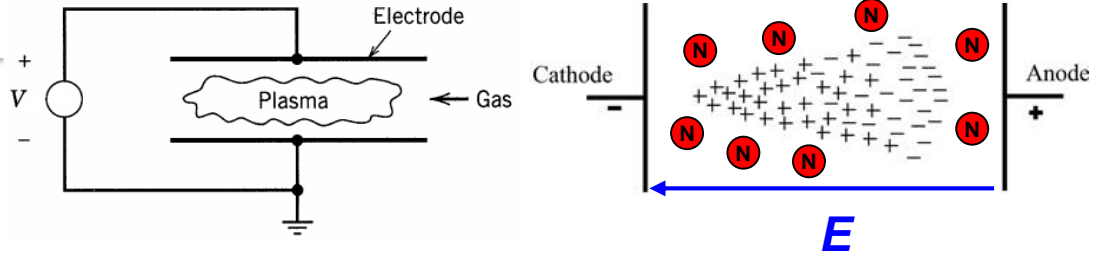
Generation of LT Plasmas and Basic Properties



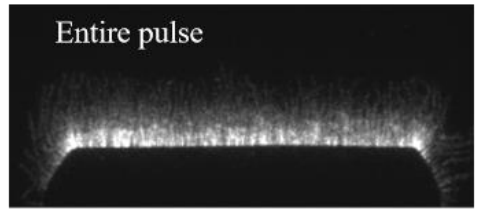
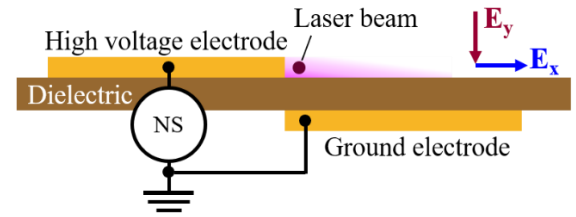
Gas Discharges as Low Temperature Plasmas

We use electric fields instead of heat!

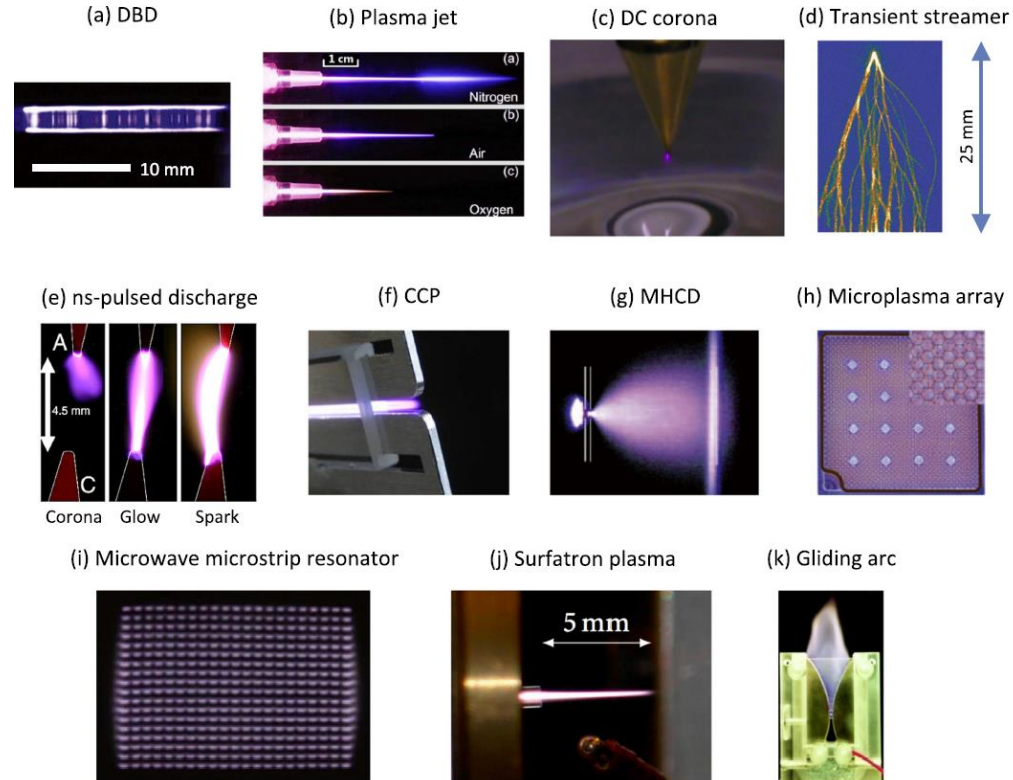
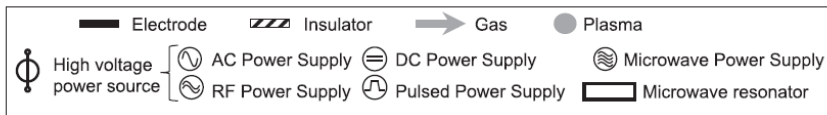
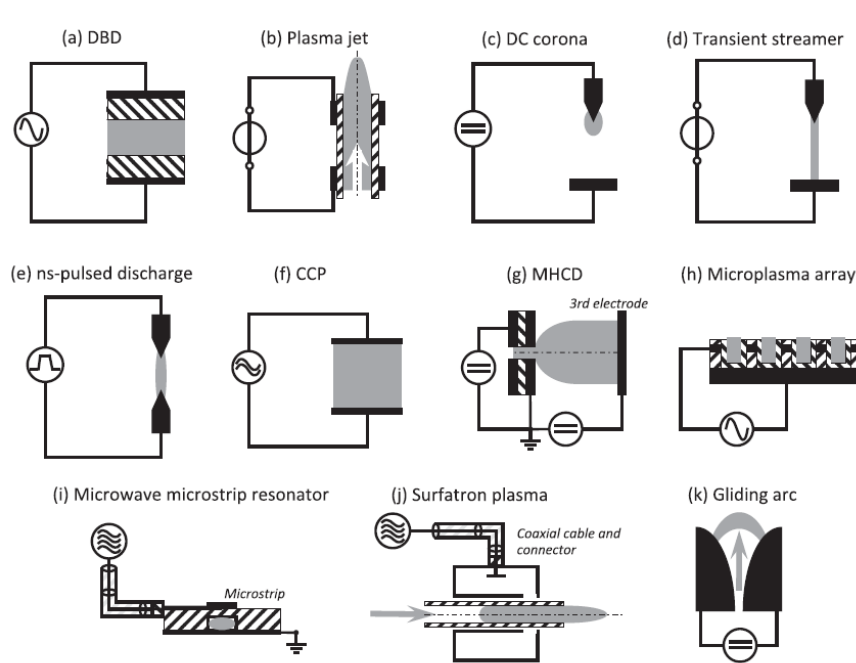
- Electrically driven
- Different excitation sources can be employed: DC, AC, RF, Microwave, nanosecond pulsed,...
- The source of energy is the E-field
- High E-fields lead to ionizing collisions
- Charged particles collisions with neutrals cause the main energy transfer from the electric field energy to the gas
- When the energy transfer of electrons to neutral particles is not very fast, the energy of electrons ($=T_e$) can be significant larger than the neutral particles energy ($=T_g$): $T_g \ll T_e$



Surface dielectric barrier discharge



Overview of Atmospheric Pressure LT Plasmas



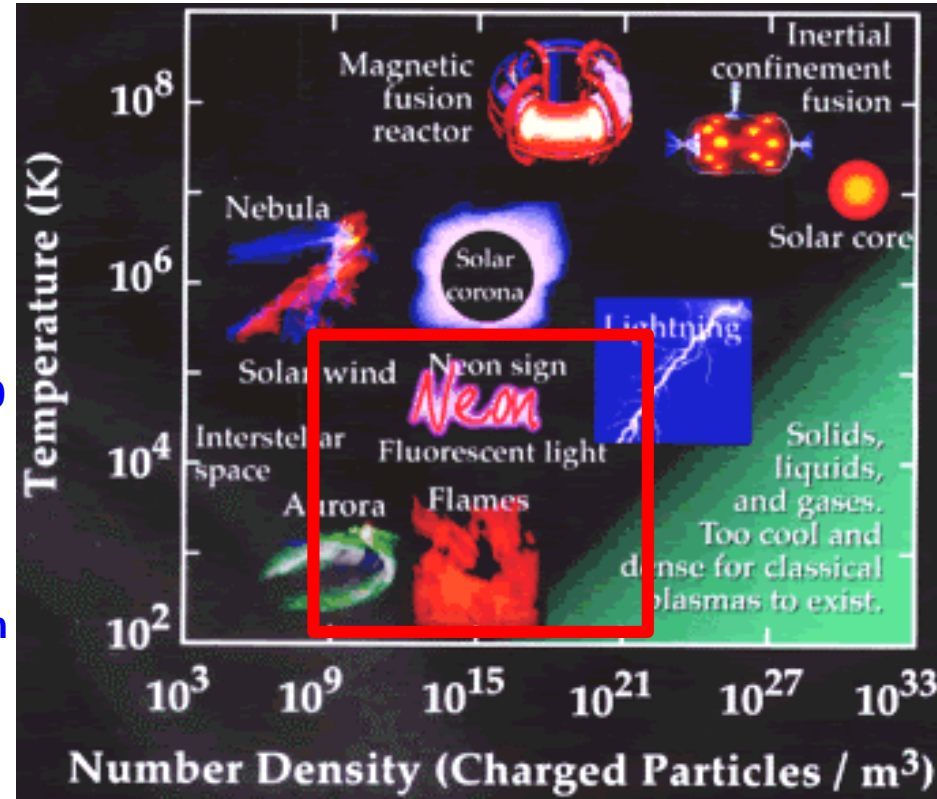
Bruggeman et al, Plasma Sources Sci. Technol. 26 (2017) 123002



LT Plasmas are Rich of Physics and Chemistry

- Span over 12 orders of magnitude for n_e
- Often low ionization fraction (degree): $\frac{n_e}{N} < 1\%$
- Ions and neutrals temperatures are near room temperature: $T_i \sim T_g \sim \frac{1}{40} \text{ eV}$
- Electron temperature can reach several eV: $T_e \sim 1\text{-}10 \text{ eV}$
- **Highly non-equilibrium**
- Highly reactive plasmas can be generated near room gas temperatures
- In presence of molecular gases, dissociation can occur generating a very rich and complex electrons-driven chemistry: **LT plasma = chemical processor**

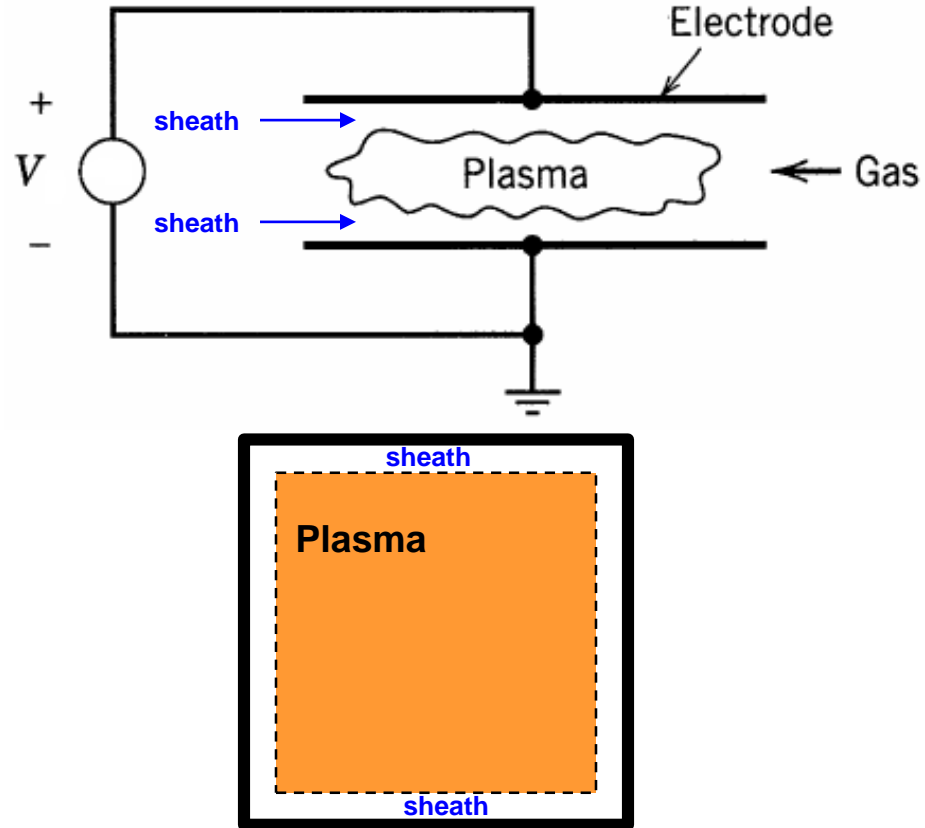
1 eV \approx 11,606K



Plasma Interactions with Surfaces: Formation of Sheaths

Plasma are surrounded by Sheaths!

- The sheath is the boundary layer between a plasma and a solid surface (electrodes, substrate, container walls, ...)
- It acts to balance electron and ion currents lost from a plasma
- Sheaths are characterized by a strong E-field, low electron density
- Sheaths form as ions are accelerated into surfaces
- Sheaths have an important role for applications relevant to: removal of surface material and ion implantation



Sheaths size depends on the plasma density (pressure)

The Debye length is the characteristic length scale of a plasma

- It's the distance scale over which significant charge densities can spontaneously exist

Using Poisson's equation:

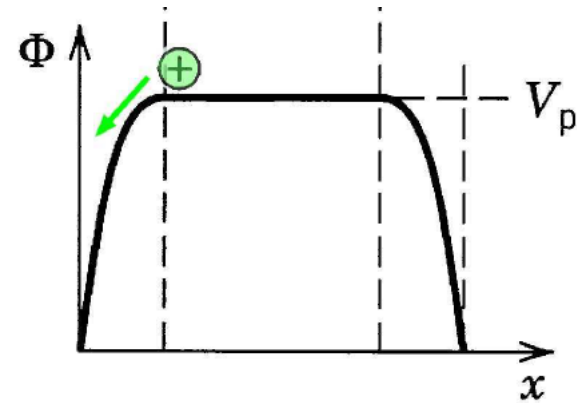
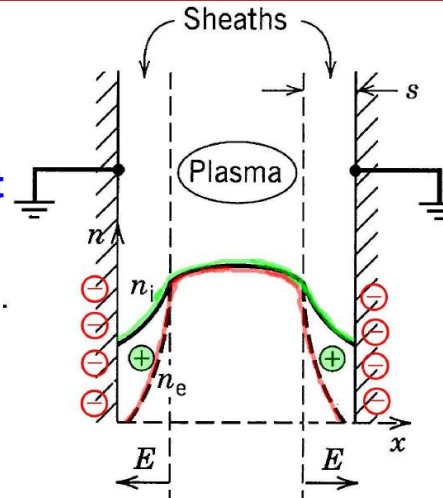
$$\phi = \phi_0 e^{-|x|/\lambda_{De}} \quad \lambda_{De} = \left(\frac{\epsilon_0 T_e}{en_e} \right)^{1/2}$$

$$\lambda_{De} (cm) = 740 \sqrt{T_e/n_e} \quad T_e \text{ in eV and } n_e \text{ in } cm^{-3}$$

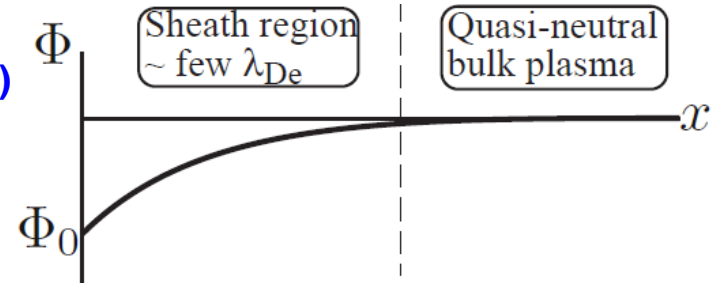
- For $T_e = 4 \text{ eV}$ and $n_e = 10^{10} \text{ cm}^{-3}$, $\lambda_{De} \sim 148 \text{ } \mu\text{m}$ (quite small!)

- Sheath thickness l_s provided by Child-Langmuir sheath model:

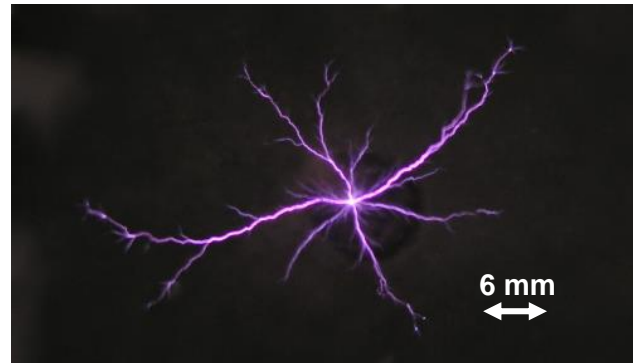
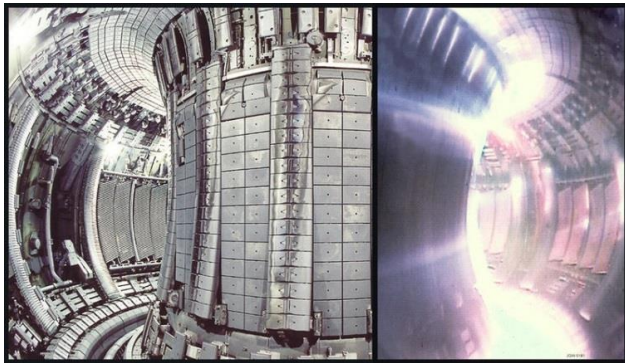
$$\frac{l_s}{\lambda_{De}} = \frac{\sqrt{2}}{3} \left(\frac{2e\Delta\phi}{T_e} \right)^{3/4}$$



$$\mathbf{E} = -\nabla\phi$$



Comparison between Hot and Cold Plasmas



EFDA JET: Joint European Torus

	JET Tokamak	Atmospheric pressure plasmas
Power	~16 MW	$10^{-2} - 10$ W
Volume	~ 100 m ³	~ 10 ⁻⁸ m ³ (10 mm ³)
Power density	10⁶ W m⁻³	10⁶-10⁹ Wm⁻³
Ionization degree	FULL	$10^{-5} - 10^{-2}$
Temperature	$T_e = T_g = 10^8$ K	$T_e = 10^3 - 10^4$ K $T_g = 300 - 3000$ K
Pulse duration	~1 s	~ 10 ns up to DC

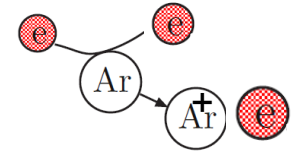
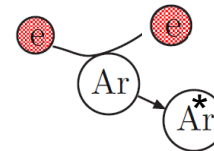
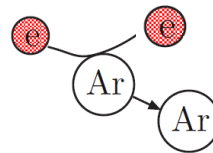
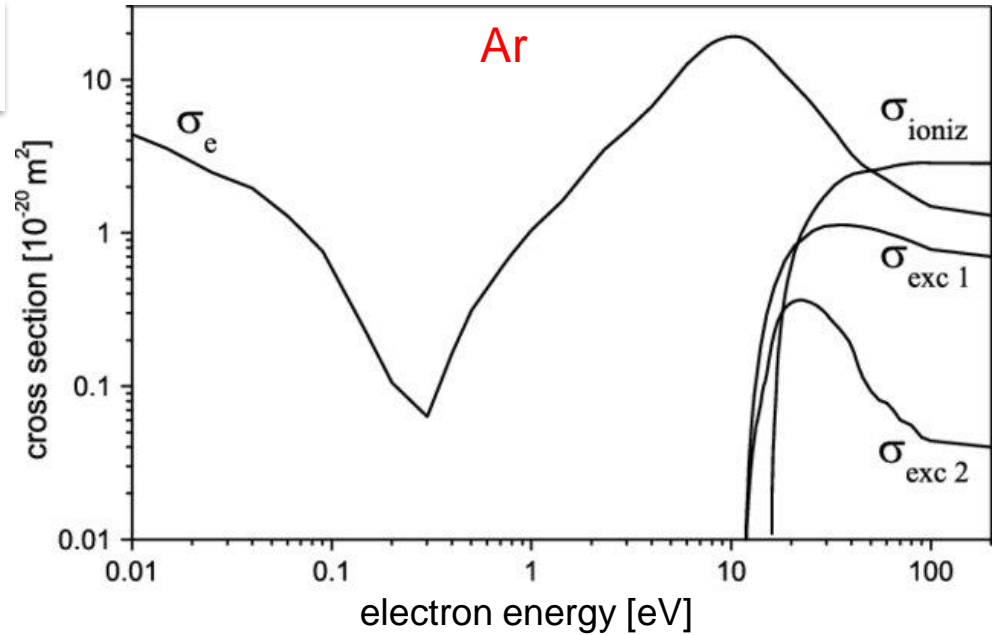
Energy Partition and Transfer in LT Plasmas



Collisions and Elementary Reactions: Atomic Gas

We use cross sections to quantify the probability that a process may occur

- **Elastic collisions:** $e^- + \text{Ar} \rightarrow \text{Ar} + e^-$
- **Electronic excitation collisions:** $e^- + \text{Ar} \rightarrow \text{Ar}^* + e^- \rightarrow \text{Ar} + e^- + \text{photons}$
- **Ionizing collisions:** $e^- + \text{Ar} \rightarrow \text{Ar}^+ + e^- + e^-$
- **Cross sections from different databases are compiled on the LXCAT website:**
<https://us.lxcat.net/>
- **Databases:** IST-Lisbon, Morgan, Phelps, Itikawa, Trinitite, Hayashi, ...
- **1 eV \sim 1.6×10^{-19} J**

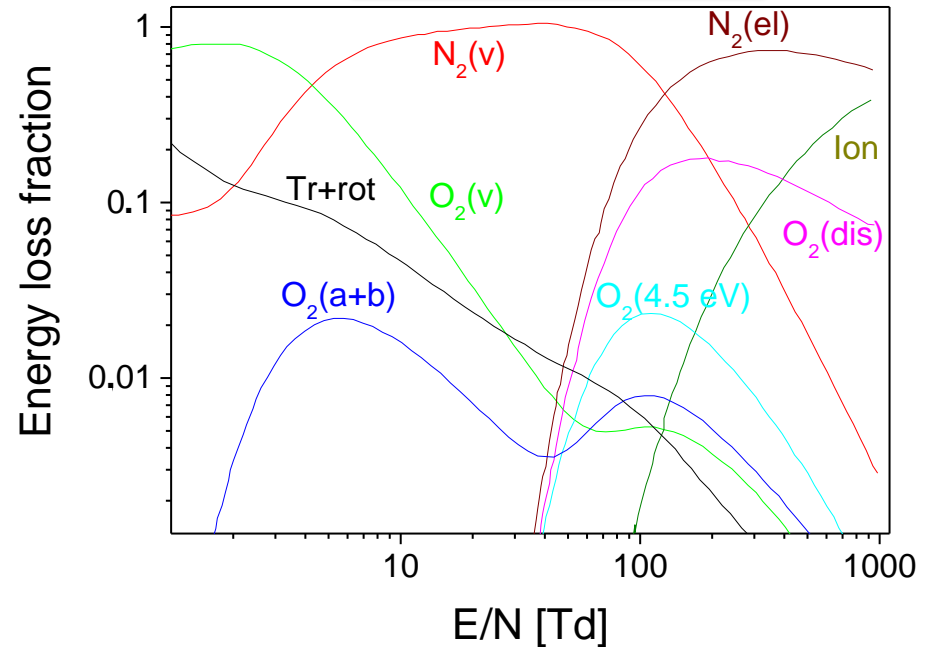


Energy Partition in a Molecular Gas: Air

Where does the energy from the electrons go?

- E/N , electric field divided by total number density
- 1 Td (Townsend) = 10^{-17} V.cm²
- The rates of electron impact processes depend exponentially on E/N
- At low E/N values (< 10 Td): Energy coupled preferentially to vibrational excitation of O_2
- For 10 Td < E/N < 100 Td: Energy coupled preferentially to vibrational excitation of N_2
- For $E/N > 100$ Td: Energy coupled into electronic excitation of N_2 , O_2 dissociation and ionization

Yuri Raizer: Gas discharge Physics



High E/N values result in high reactivity and rapid electron-driven processes. This is for instance achieved using nanosecond pulsed discharges



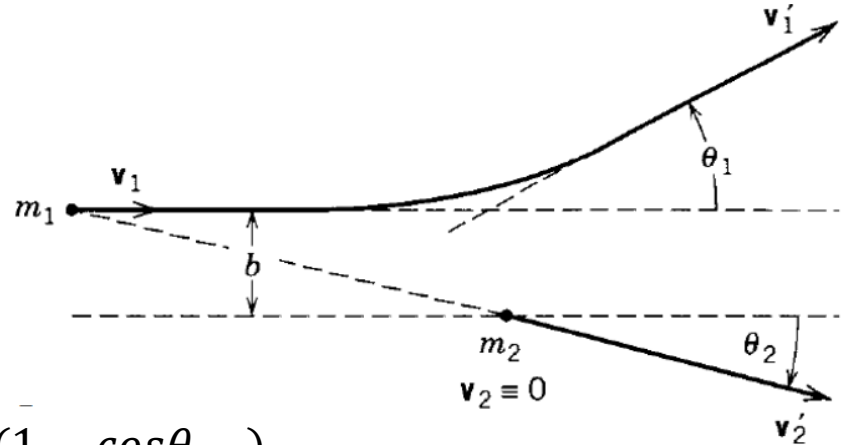
Energy Transfer in an Elastic Collision (1)

- Expressing energy and momentum balances yields:

W_L = final energy for particle m_2
 W = initial energy for particle m_1

$$\frac{W_L}{W} = \zeta_L = \frac{4m_1m_2}{(m_1 + m_2)^2} \cos^2 \theta_2 = \frac{2m_1m_2}{(m_1 + m_2)^2} (1 - \cos \theta_{CM})$$

$$\theta_2 = \frac{\pi}{2} - \frac{\theta_{CM}}{2}$$



CM = Center of Mass (given)

- What is now the average energy transfer per collision?



Energy Transfer in an Elastic Collision (2)

Fraction of energy transferred in one collision:

- For electron – neutral collision (hard sphere model)

$$\frac{2m_1m_2}{(m_1 + m_2)^2} \approx \frac{2m_e}{M} \approx 10^{-4}$$

Electrons transfer little energy in elastic collisions with neutrals: $T_e \gg T_g$

- For ion – neutral collision (with same mass)

$$\frac{2m_1m_2}{(m_1 + m_2)^2} = \frac{1}{2}$$

Equilibration rates depend on the mass ratios

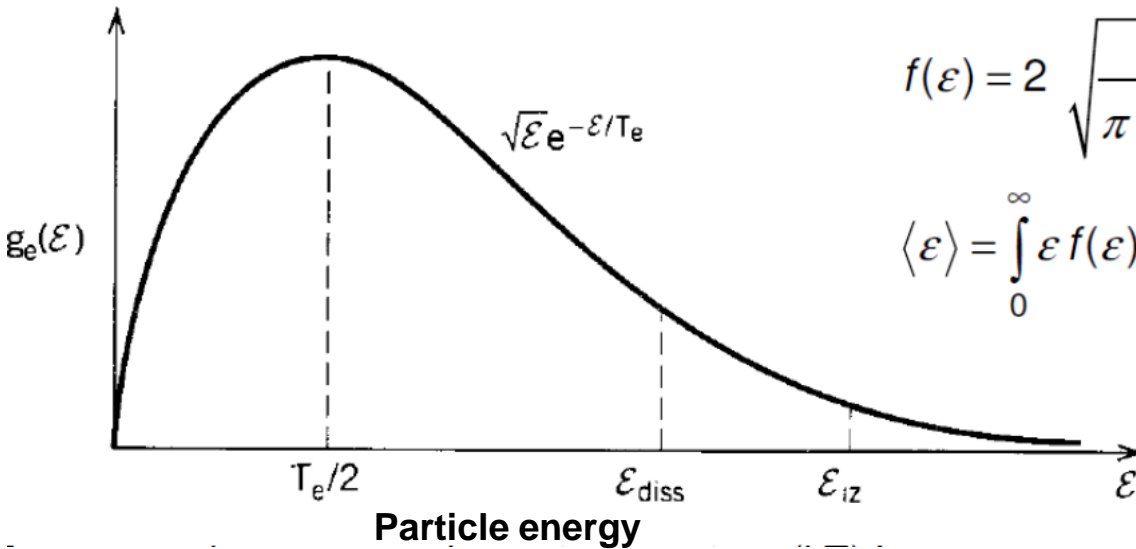
Ions neutral collisions transfer significant energy in elastic collisions: $T_{\text{ion}} \sim T_g$



What does Temperature mean?

Temperature is actually related to the mean kinetic energy!

Concept of thermal equilibrium in statistical mechanics: Maxwell-Boltzmann distribution function of the particle energy



$$f(\mathcal{E}) = 2 \sqrt{\frac{\mathcal{E}}{\pi (kT_e)^3}} \exp\left(-\frac{\mathcal{E}}{kT_e}\right)$$

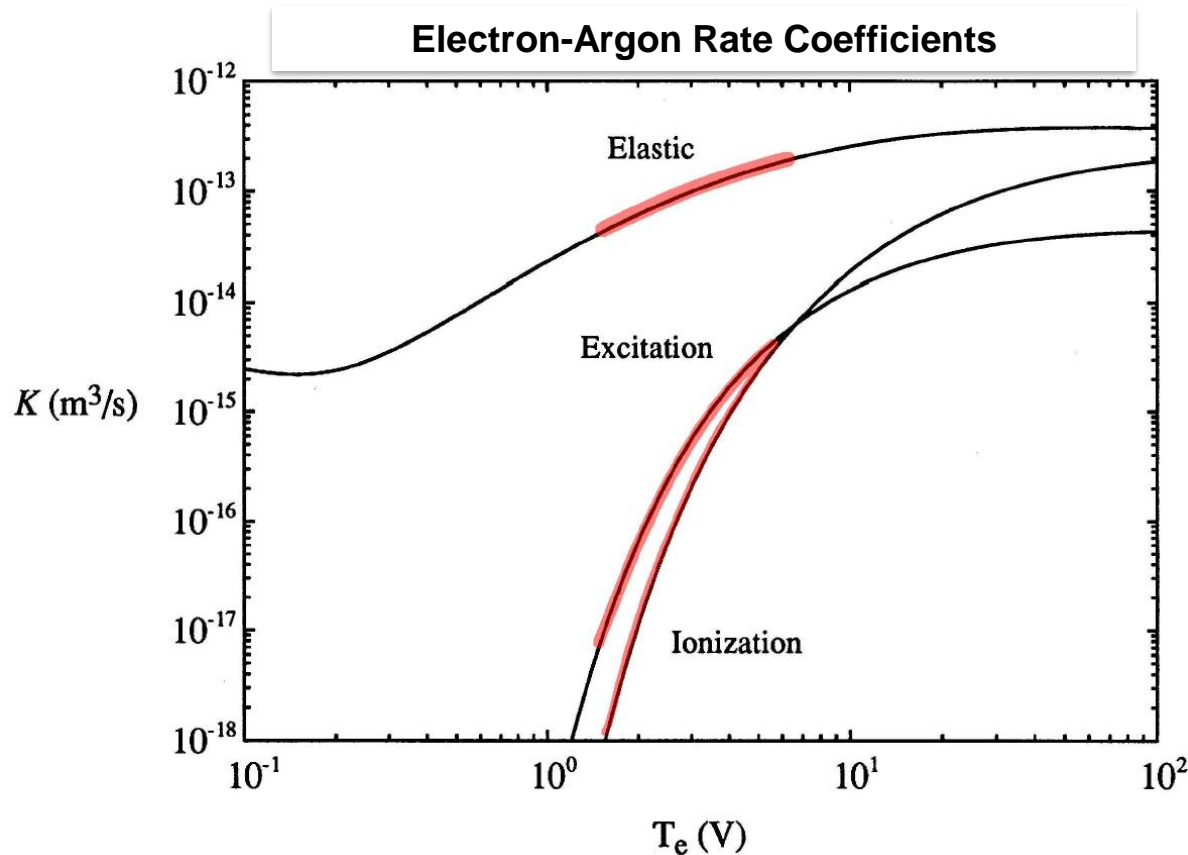
$$\langle \mathcal{E} \rangle = \int_0^{\infty} \mathcal{E} f(\mathcal{E}) d\mathcal{E} = \frac{3}{2} kT_e$$

• Ionization is caused by high energy electrons in the tail of the distribution!

• An electron temperature (T_e) of 1 eV therefore means that the plasma has an electron energy distribution function (EEDF) with a mean energy of 3/2 eV



Rate Coefficients



- Rate coefficient is the average of the cross section $\sigma(V_R)$ of the process over the Maxwellian distribution
- $K(T_e) = \langle \sigma V_R \rangle_{\text{Maxwellian}}$
- V_R = relative velocity of colliding particles
- The knowledge of rate coefficients is indispensable for establishing accurate collisional-radiative models of plasmas

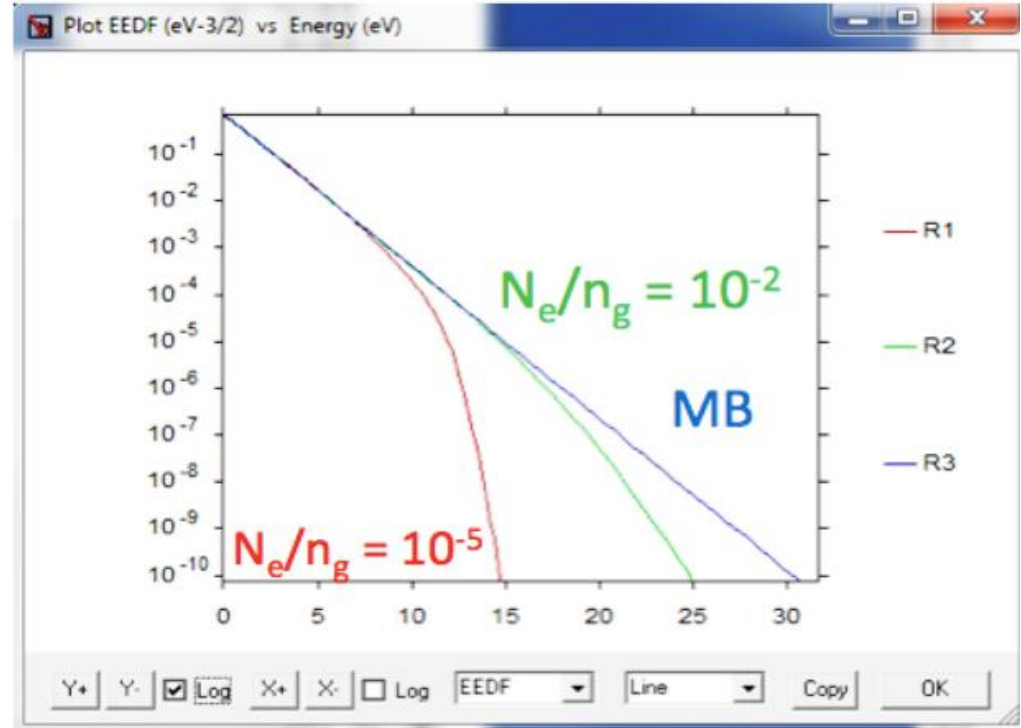


Deviation from Maxwell-Boltzmann Distribution

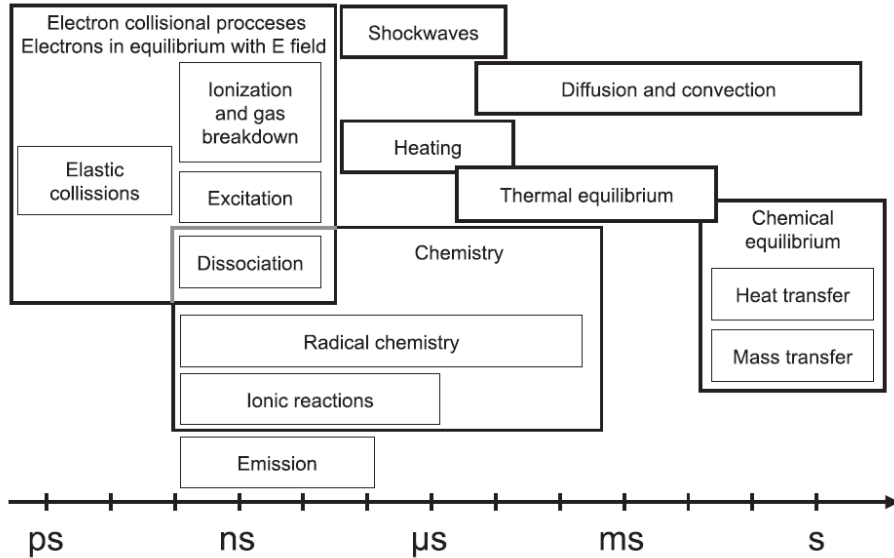
The EEDF is not necessarily Maxwell-Boltzmann!

- It depends on the ionization degree
- Assuming M-B when it is not can hugely impact rates with high threshold energy
- Plasma codes have a Boltzmann solver (EEDF can depend on gas composition)

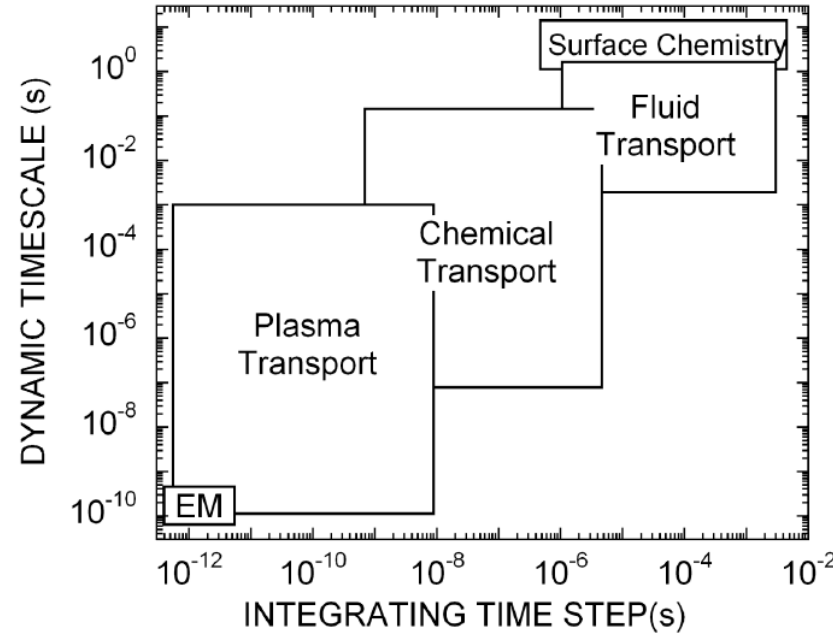
Bolsig+: Boltzmann equation solver



LT Plasmas Modeling and Timescales



- About 12 orders of magnitude in timescales
- Integrating timestep (stability, accuracy): Δt
- Dynamic timescale (to resolve the evolution of plasma phenomena): ΔT



Mark J. Kushner, University of Michigan

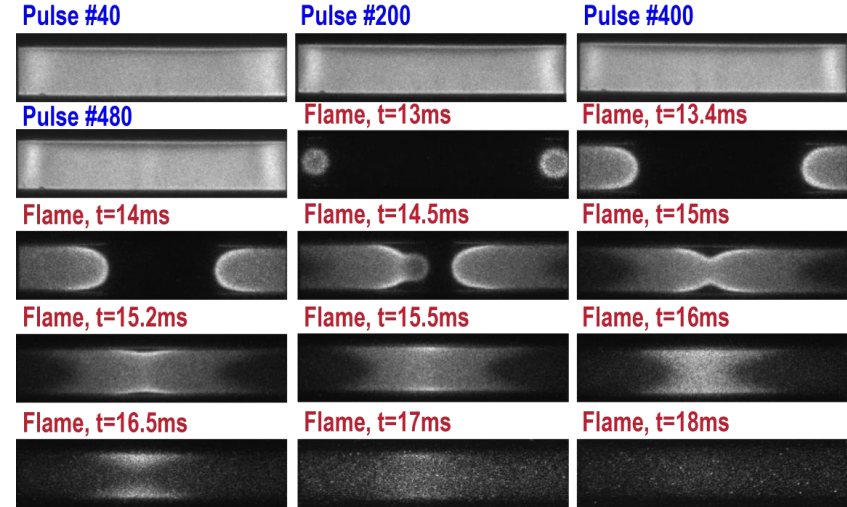
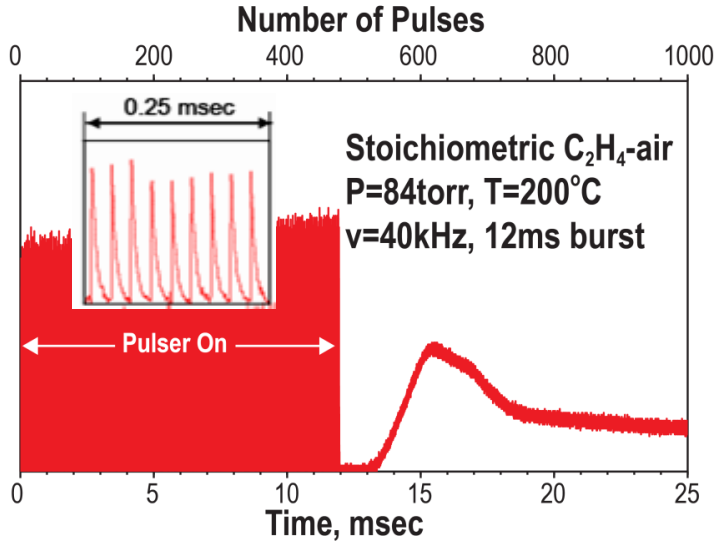
Bruggeman et al, Plasma Sources Sci. Technol. 26 (2017) 123002



Case Study #1: Plasma-Assisted Ignition



C₂H₄ Ignition below Auto-ignition Temperature



OH emission from plasma and flame

- Ignition induced by radicals generated in the plasma (primarily O and H atoms)
- Ignition occurs at temperature ≈ 200 K below autoignition
- Ignition begins near edges of the plasma (higher energy loading)
- Flame propagates to the center of the plasma

Yin et al, IEEE Trans Plasma Sci. 2011

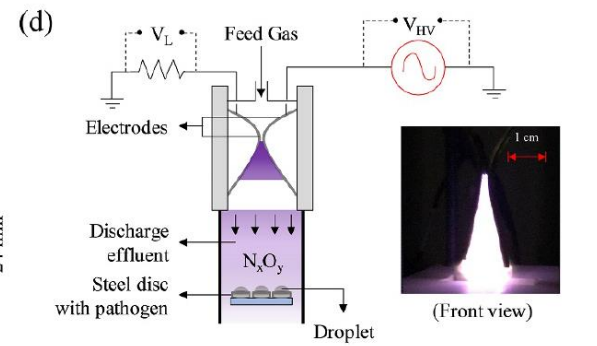
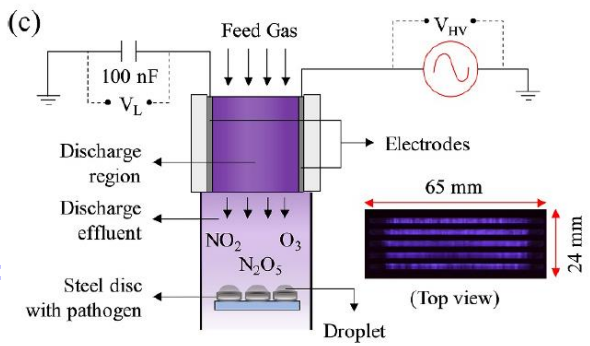
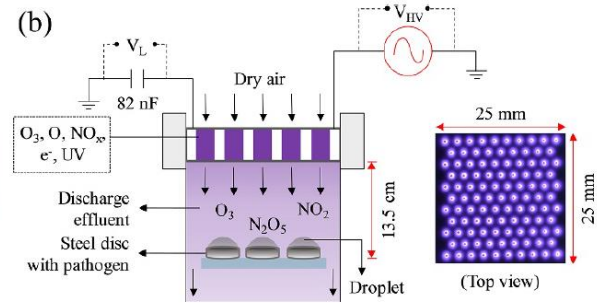
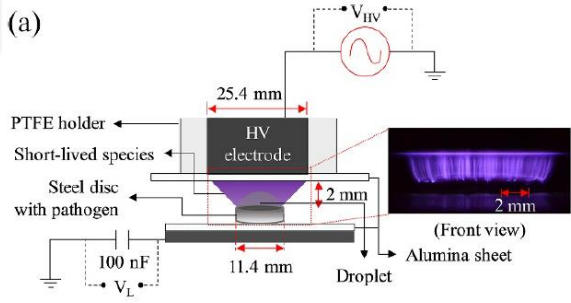
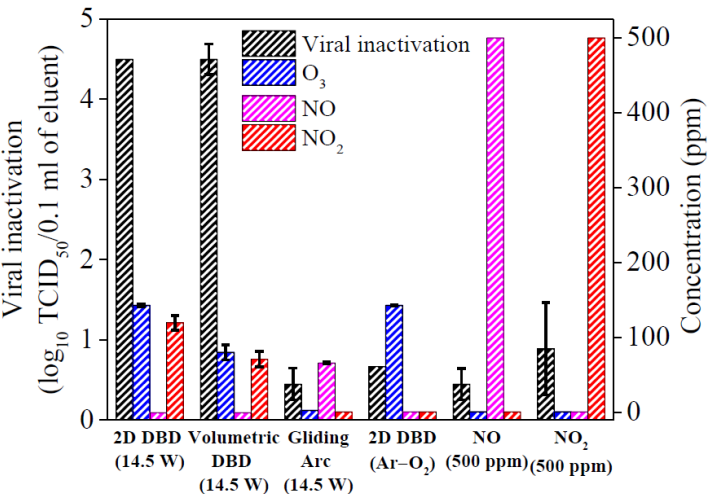


Case Study #2: Inactivation of Viruses and Bacteria



RONs from Air Plasmas for Virus Inactivation

RONs = Reactive Oxygen Nitrogen Species



FCV = Feline CaliciVirus (surrogate of human norovirus = stomach flu)

- **Reactive components from plasma chemistry:** O₃, NO_x, OH, O, H₂O₂, N₂⁺, O₂⁺, O₂⁻, UV light, e⁻
- **Comparison of surface decontamination efficiency of 4 different plasmas**
- **Strong correlations between generation of gas phase N₂O₅ and inactivation**



Case Study #3: Polymer Etching



Etching from O, H, OH Produced by a RF Plasma Jet

- Etching of polystyrene, PMMA (poly methyl methacrylate) and PVA (poly vinyl alcohol)

- Ar+1% O₂, Ar+1% air, Ar +1% H₂O plasma jets

- Correlation between O flux at the surface and polymer etching rate

- Etching probability of polystyrene by OH at least one order of magnitude greater than etching of polystyrene by O radicals

Using plasma to modify surface properties of polymers:
Improving adhesion, printing and biocompatibility

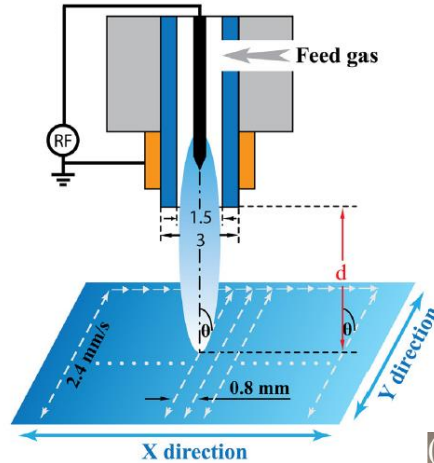
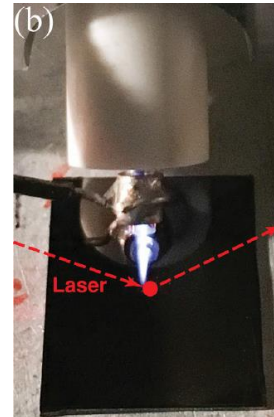


TABLE VI. Obtained etching probability (γ) for different surface loss coefficients (β).

Species	β	γ
O [•]	10^{-4}	$(1.9 \pm 0.1) \times 10^{-5}$
	10^{-3}	$(3.2 \pm 0.2) \times 10^{-5}$
	10^{-2}	$(1.4 \pm 0.2) \times 10^{-4}$
H [•]	10^{-5}	$< 8.3 \times 10^{-6}$
	10^{-3}	$< 1.8 \times 10^{-5}$
	10^{-2}	$(2.8 \pm 0.1) \times 10^{-3}$
OH [•]	10^{-2}	$(5.750 \pm 0.001) \times 10^{-3}$
	10^{-1}	$(3.5 \pm 0.1) \times 10^{-2}$



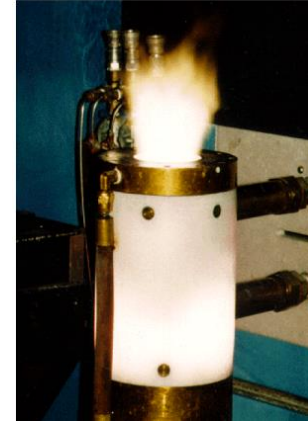
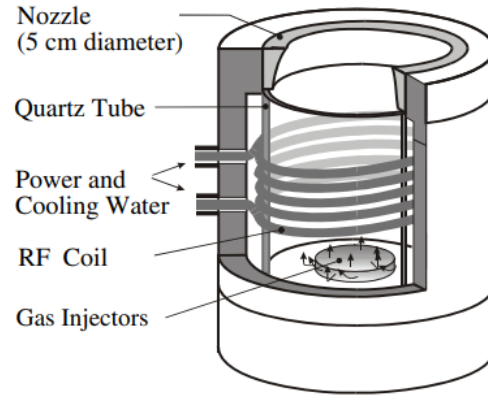
Luan et al, J. Phys. D: Appl. Phys. 50 (2017) 03LT02

Kondeti et al, J. Vac. Sci. Technol. A 38(3)



Non-equilibrium Flows during Earth Atmospheric Reentry

Plasma Torch Facility at Ecole Centrale Paris



- Earth reentry occurs at hypersonic velocities: $5\text{-}20 \text{ km.s}^{-1}$
- Radiative fluxes from the shock-produced plasma account for up to 50% of the total heat encountered by a spacecraft during reentry
- The plasma generated is under non-equilibrium conditions
- Designing effective thermal protective systems (TPS) require accurate quantification of these radiative fluxes
- Experiments performed in ground facilities use plasma torches and arc jet plasmas

MacDonald et al, J. Thermophys. Heat Trans 29.1 (2015)



Summary

- LT plasmas are everywhere around us
- They enable many of our modern technologies
- LT plasma physics a multidisciplinary field
- Their high non-equilibrium feature provides an almost infinite richness
- LT plasmas are relatively easy to generate in the lab. This leads to the research field being exciting and fast-paced
- Ongoing work involves theory, modeling, computational and experimental efforts
- **Come join us!**





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